

## REMARKS

Favorable reconsideration is respectfully requested in view of the foregoing amendments and following remarks.

A typographical error has been corrected on page 30 of the Specification.

The original Abstract has been cancelled and a new Abstract has been substituted therefore in compliance with PTO rules.

Accordingly, the objection to the Abstract is deemed to be overcome.

Claim 1 has been amended to incorporate the subject matter of claim 2. Claim 2 was not encompassed by the rejection of claim 1 under 35 USC 102. Applicant acknowledges with thanks the Examiner's indication that claims 2-4 would be allowable if rewritten in independent form.

Accordingly, it is believed that the 102 rejection has been overcome.

New claims 5-11 have been added.

Regarding new claim 5, the basis of the amendments is present claim 1.

Regarding new claim 6, the basis of the phrase "an aryl group or a substituted aryl group" of  $R^1$  is the specification at page 6, the last line and page 7, line 4, and the basis of the phrase "hydrocarbon" of  $R^4$  is the specification at page 14, line 15.

Regarding new claim 7, the basis of the phrase "an aryl group" of  $R^1$  is the specification as mentioned above regarding the new claim 6, and the basis of the phrase "alkyl group" of  $R^4$  is the specification at page 14, line 18 and page 6, line 27.

Regarding new claim 8, the basis of the phrase "a methyl group" of  $R^4$  is the specification at page 14, line 18, page 6, line 27 and page 7, line 7.

Regarding new claim 9, the basis of the two specific compounds of the formula (2) and the two specific compounds of the formula (1) is the working examples 1 and 2.

Regarding new claim 10, the basis of the specific enumerated asymmetric metal complexes is the specification at page 26, lines 11-24.

Regarding new claim 11, the basis of the specific asymmetric metal complex is the specification at page 26, line 16.

In view of the foregoing, it is believed that the application is in condition for allowance. Accordingly, such allowance is solicited.

Respectfully submitted,

Tohru YOKOZAWA et al.

By: Warren M. Cheek, Jr.  
Warren M. Cheek, Jr.  
Registration No. 33,367  
Attorney for Applicants

WMC/dlk  
Washington, D.C. 20006-1021  
Telephone (202) 721-8200  
Facsimile (202) 721-8250  
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